

Special Issue

Applied Computational Fluid Dynamics (CFD)

Message from the Guest Editors

This Special Issue on “Applied Computational Fluid Dynamics” is proposed, in which best practices, new methods, results, and frameworks can be presented aiming for the mutual advancement of the field as a whole. Furthermore, we aim to:

- Highlight the breadth of applied CFD modeling;
- Identify novel and emerging methods, capabilities, and applications;
- Explore limitations in existing capabilities and sources for validation.

Guest Editors

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Deadline for manuscript submissions

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Editor-in-Chief

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